
Symposium | Symposium | Advanced CMOS Technology and Its Future Scope

[11p-B5-1~9]Advanced CMOS Technology and Its Future Scope

Wed. Mar 11, 2015 1:15 PM - 5:30 PM B5 (6B-105)

△ : Young Scientist Oral Presentation Award Applied

▲ : English Presentation

▼ : Both Award Applied and English Presentation

5:00 PM - 5:30 PM

[11p-B5-9]Passivation Schemes for Ge High-K Metal Gate MOSFETs on Si for VLSI Production

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Keywords:High mobility channel material